



Features

- 5.5 kOe (0.55 T) horizontal (in-plane) field electromagnet
- 360° sample stage rotation option
- High stability operation from 3.2 K to 400 K
- Measurements from DC to 67 GHz
- Accommodates up to 25 mm (1 in) diameter wafers
- Configurable with up to four thermally anchored micro-manipulated probe arms
- Probe arms with 3-axis adjustments and $\pm 5^\circ$ planarization
- Cables, shields, and guards minimize electrical noise and thermal radiation losses
- Options and accessories for customization to specific research needs

Model EMPX-HF ELECTROMAGNET-BASED HORIZONTAL FIELD CRYOGENIC PROBE STATION

Introduction

The Model EMPX-HF is a versatile cryogenic electromagnet-based micro-manipulated probe station used for non-destructive testing of devices on full and partial wafers up to 25 mm (1 in) in diameter. The EMPX-HF is a platform for measurement of magneto-transport, electrical, electro-optical, parametric, high Z, DC, RF, and microwave properties of materials and test devices. Nanoscale electronics, quantum wires and dots, semiconductors, superconductors, and spintronic devices are typical materials measured in an EMPX-HF. A wide selection of probes, cables, sample holders, and options makes it possible to configure the EMPX-HF to meet your specific measurement applications.

Mounted on a vibration isolation table, the EMPX-HF is equipped with a 5.5 kOe (0.55 T) horizontal (in-plane) field electromagnet. The EMPX-HF operates over a temperature range of 4.5 K to 400 K. With options, the base temperature can be extended down to 3.2 K. The probe station provides efficient temperature operation and control with a continuous refrigeration system using either liquid helium or liquid nitrogen. Field dependent measurements at ambient temperature are possible without the use of cryogens. Liquid helium is only required for cooling the device under test (DUT) to below 80 K. Vapor-cooled shielding optimizes efficiency and intercepts blackbody radiation before it reaches the sample. A heater on the sample stage along with independent control of radiation shield heaters provides the probe station with fast thermal response.

The EMPX-HF is user configured with up to four ultra-stable micro-manipulated stages, each providing precise 3-axis control of the probe position to accurately land the probe tip on device features. The 360° sample stage rotation option allows you to measure angular-dependent and anisotropic magneto-transport properties of the DUT. Proprietary probe tips in a variety of sizes and materials minimize thermal mass and optimize electrical contacts to the DUT. Probe tips are thermally linked to the sample stage to minimize heat transfer to the DUT.

For increased versatility, EMPX-HF options include a 3.2 K base temperature stage, 360° sample stage rotation, a LN₂ Dewar kit, higher magnification microscope, vacuum turbo pumping system, pump-line vibration isolator, recirculating chillers, and fiber optic probe arm modification.

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Applications

- Angular-dependent and anisotropic magneto-transport measurements
- Electrical and electro-optical measurements over a wide temperature range
- RF and microwave
- Parametric testing
- Shielded/guarded/low noise characterization
- High Z
- Non-destructive, full wafer testing

Materials

- Nanoscale electronics (carbon nanotube transistors, single electron transistors, molecular electronics, nanowires, etc.)
- Quantum wires and dots, quantum tunneling
- Single electron tunneling (Coulomb blockade)
- Superconductors
- Spintronic devices
- Basic semiconductor devices including organics, LEDs, and dilute magnetic semiconductors

Specifications

Magnetic Field

Maximum field	5.5 kOe (0.55 T)*
Probe movement due to magnet field ramping to 5.5 kOe (0.55 T)	<5 μm
Field uniformity (at 70 A)	
10 mm diameter wafer	0.6%
12.7 mm diameter wafer	1.1%
20 mm diameter wafer	2%
25.4 mm diameter wafer	2.6%
Field control stability	<50 mG RMS**

*Hall probe is calibrated to read field at the center of the magnet gap

**With settle band of 100 mG

Temperature

Sample temperature range—standard	4.5 K to 400 K*	
Sample temperature range—optional	3.2 K to 400 K**	
Temperature control (heaters)		
Sample stage	100 W	
Radiation shields	Two, 100 W each	
Probe arm	Measurement only	
Temperature control stability		
With LHe	5.5 K to 50 K	<5 mK RMS
	50 K and higher	<50 mK RMS
With LN ₂	80 K and higher	<100 mK RMS

*Limited from 8 K to 400 K when configured with the PS-360-EMPX 360° sample stage rotation option

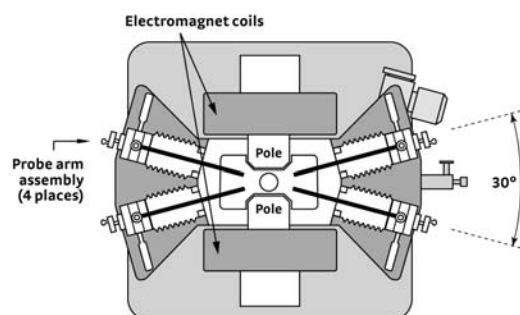
**Selectable equipment

Probe Arm Adjustments

Travel	
X axis	51 mm (2 in)
Y axis	25 mm (1 in)
Z axis	18 mm (0.7 in)
Translation scale	
X axis	20 μm
Y and Z axes	10 μm
Planarization*	±5°
Sample stage (sample holder) in-plane rotation**	
	360°

*Included with microwave probes

**Optional — recommended when taking measurements using microwave probes



NOTE: because of the location of the magnet poles in the EMPX-HF, the probes are aligned at 30° angles, which limits probe tip proximity (probe-dependent). Contact Lake Shore for more information.

Frequency Range

ZN50 DC/RF probe frequency range	
Tungsten with cryogenic coaxial cable	0 to 50 MHz*
Tungsten with semirigid coaxial cable	0 to 1 GHz*†
Paliney 7 with cryogenic coaxial cable	0 to 50 MHz*
Paliney 7 with semirigid coaxial cable	0 to 1 GHz*†
BeCu with cryogenic coaxial cable	0 to 50 MHz*
BeCu with semirigid coaxial cable	0 to 1 GHz*†
GSG microwave probe frequency range	
Low frequency with K connector	0 to 40 GHz*
Mid frequency with 2.4 mm connector	0 to 50 GHz*
High Frequency with 1.85 mm connector	0 to 67 GHz*

*Selectable equipment

† S21 > -10 dB up to 1 GHz, except for a (-40 dB) spike between 400 MHz and 800 MHz depending on probe model and placement; S11 < -3 dB up to 1 GHz

Optical

Optical viewport—located on top lids	Ø54 mm (2.13 in) outer window and Ø50 mm (2 in) inner window
Outer, clear fused quartz	99% IR transmittance
Inner	IR absorbing with narrow band visible light transmittance
Optical resolution—microscope	
7:1 zoom	8 µm
16:1 zoom	8 µm*

*Selectable equipment

Sample Holders

Maximum sample size—overall	Up to Ø25 mm (1 in)
SH-1.00-G-EM, grounded	Up to Ø25 mm (1 in) and 400 K
SH-1.00-I-EM, isolated	Up to Ø25 mm (1 in) and 400 K*
SH-1.00-C-EM, coaxial**	Up to Ø25 mm (1 in) and 400 K*
SH-1.00-T-EM, triaxial**	Up to Ø25 mm (1 in) and 400 K*

*Selectable equipment

**Not available in combination with the 360° sample stage rotation feature

Standard Equipment

Electromagnet	5.5 kOe (0.55 T), horizontal field
Water flow rate	7.6 L/min (2 gal/min)
Electromagnet power supply	Lake Shore Model 642
Output type	Bipolar, linear, 4-quadrant, DC current source
Current	±70 A
Voltage	±35 V
Water flow rate	5.7 L/min (1.5 gal/min)
Gaussmeter and Hall probe	Lake Shore Model 475 with probe (control and monitor field)
Flow cryostat	4.5 K to 400 K
Sample stage temperature sensor	Lake Shore Model CX-1050-SD-HT-1.4M calibrated Cernox™ RTD
Sample stage heater	100 W
Cooled radiation shield and cooled IR-absorbing window above the sample	
Radiation shield temperature sensors	Two Lake Shore Model DT-670C-CU silicon diodes
Radiation shield heaters	Two 100 W
Removable top lid with viewport	Ø50 mm (2 in) window
Temperature control	One Lake Shore Model 336 temperature controller and one Model 142 200 W (two channels, 100 W each) power supply (independent regulation of sample stage and radiation shield, and probe arm temperature monitoring)
Electroless nickel-plated aluminum vacuum chamber	
Outside dimensions	340 mm × 203 mm (13.4 in × 8 in)
Removable top lid with clear fused quartz viewport	Ø54 mm (2.13 in) window
Probe ports	4 surround the sample thermal radiation shield
Pump port	NW 40 (pump sold separately)
Gas purge and 0.5 psi safety pop-off port	NW 25
Machined aluminum base plate	787 mm × 419 mm (31 in × 16.5 in)
PS-TMC vibration isolation system	
	Includes pneumatically driven gimbal piston isolator, actuators, and supports; self leveling with a resonant frequency below 2 Hz; requires 40 psi nitrogen or air
Isolator natural frequency	Vertical 0.8 Hz, horizontal 1.0 Hz
Isolator efficiency at 5 Hz	Vertical 80 to 97%, horizontal 60 to 90%
Isolator efficiency at 10 Hz	Vertical 90 to 99%, horizontal 70 to 95%
Temperature sensor installed and wired to a 6-pin feedthrough (included on one probe arm)	
Grounded sample holder	SH-1.00-G-EM, accommodates up to a Ø25 mm (1 in) sample with a Ø25 mm (1 in) probe area
Optics	
Zoom 70 microscope	7:1 zoom with 8 µm resolution
Color CCD camera	S-video or composite output format
Swing arm	Optics can be manipulated to view any part of the sample or wafer, and can be retracted and swung away to allow access to the top of the vacuum chamber for sample exchange
Video monitor	High resolution, 17-inch
Sample illumination	Coaxial via fiber optic or ring light from an adjustable light source and power supply (must specify sample illumination at time of order) NOTE: Coaxial illumination is recommended for highly reflective materials
High efficiency helium transfer line with foot valve for precise flow regulation	
Instrument console	
Basic tools and spares kit for standard operation	

Required User Configurable Equipment — Micro-manipulated Stages, Probes, Probe Tips, and Cables

UP TO FOUR XYZ PRECISION MICRO-MANIPULATED STAGES

Part Number	Description
MMS-10	Micro-manipulated stage with thermal radiation shields, stainless steel welded bellows, and feedthrough ports—includes probe arm and base; probes, probe tips, and cables sold separately

ZN50 DC/RF PROBES

- Ideal for: DC biasing, low/high frequency measurements, low noise shielded, and low-leakage guarded measurement
- ZN50 probe base incorporates a pair of copper braids that anchor to the sample stage to dynamically cool/heat the probe to the sample temperature
- SMA connector mounted directly to an alumina ceramic blade with a 50 Ω stripline routed to the probe contact

We understand that today's researcher requires flexibility. Our wide selection of probes, cables, sample holders, and options make it possible to configure a probe station to meet your specific measurement applications.

Part number (probe body)	Description
ZN50	50 Ω stripline probe body mount (each probe body mount requires a ceramic blade—selectable below)

Part number (probe body and ceramic blade)	Tip material	Maximum frequency (GHz)	Maximum probe temperature*	Maximum sample temperature**	Tip radius (μm)
ZN50R-03-W	Tungsten	1 Maximum frequency 50 MHz with ZN50C-G or ZN50C-T cable; maximum frequency 1 GHz with MWC-10-00K-NM cable	350 K	400 K	3
ZN50R-10-W					10
ZN50R-25-W					25
ZN50R-03-P7	Paliney 7				3
ZN50R-10-P7					10
ZN50R-25-P7					25
ZN50R-03-BECU	BeCu				3
ZN50R-10-BECU					10
ZN50R-25-BECU					25
ZN50R-100-BECU					100
ZN50R-200-BECU		200			

* As measured by the probe arm temperature sensor

** Selectable equipment

ZN50 DC/RF CABLES

Part number	Cable type	Connector type	Feedthrough type	Measurement configuration	Maximum frequency	Maximum cable temperature*	Maximum sample temperature**
ZN50C-G	Ultra-miniature cryogenic coaxial	SMA	BNC	Shielded	50 MHz	350 K	400 K
ZN50C-T	Ultra-miniature cryogenic coaxial	SMA	3-lug triaxial	Low leakage	50 MHz		
MWC-10-00K-NM	Non-magnetic semirigid microwave coaxial	K (SMA compatible)	Loss-less compression seal	High frequency	1 GHz [†]		

* As measured by the probe arm temperature sensor

** Selectable equipment

[†] S21 > -10 dB up to 1 GHz, except for a (-40 dB) spike between 400 MHz and 800 MHz depending on probe model and placement; S11 < -3 dB up to 1 GHz

GSG MICROWAVE PROBES*

- Coplanar waveguide probe with ground-signal-ground (GSG) contact geometry
- User-specified pitch (spacing)
- Optimized low thermal conductivity coaxial leading to low thermal conductivity tips
- Cooled to near-sample temperature
- Separate planarization module with $\pm 5^\circ$ rotation mechanism is provided

Part number	Connector type	Maximum frequency (GHz)	Maximum probe temperature* [†]	Maximum sample temperature**	Pitch (μm)
GSG-050-40A-E-NM	K	40	350 K	400 K	50
GSG-100-40A-E-NM					100
GSG-150-40A-E-NM					150
GSG-200-40A-E-NM					200
GSG-250-40A-E-NM					250
GSG-050-50A-E-NM	2.4 mm	50	350 K	400 K	50
GSG-100-50A-E-NM					100
GSG-150-50A-E-NM					150
GSG-200-50A-E-NM					200
GSG-250-50A-E-NM					250
GSG-050-67A-E-NM	1.85 mm	67	350 K	400 K	50
GSG-100-67A-E-NM					100
GSG-150-67A-E-NM					150
GSG-200-67A-E-NM					200
GSG-250-67A-E-NM					250

* As measured by the probe arm temperature sensor

** Selectable equipment

[†] PS-360-EMPX 360° sample stage rotation option; recommended when taking measurements using microwave probes

GSG MICROWAVE CABLES

- Loss-less compression seal
- Semirigid with Teflon® dielectric

Part number	Cable type	Feedthrough type	Maximum cable temperature*	Maximum sample temperature**	Connector type	Maximum frequency
MWC-10-00K-NM	Non-magnetic semirigid microwave coaxial	Loss-less compression seal	350 K	400 K	K (SMA compatible)	40 GHz
MWC-10-240-NM					2.4 mm	50 GHz
MWC-10-185-NM					1.85 mm	67 GHz

* As measured by the probe arm temperature sensor

** Selectable equipment

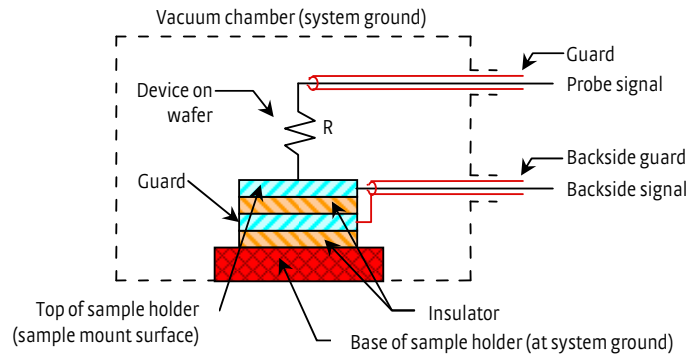
Sample Holders

Typical sample holder configuration characterized by:

- Leakage resistance between
 - Top surface and guard
 - Guard and ground
- Capacitance between
 - Top surface and guard
 - Guard and ground

Types of sample holders

- Grounded sample holder—sample mount surface at system ground
- Isolated sample holder—backside contact not needed; sample mount surface is electrically non-conductive and isolated from ground
- Coaxial sample holder—backside contact can be made; sample mount surface is isolated from ground
- Triaxial sample holder—guarded backside contact can be made; sample mount surface has guarded isolation from ground



Part number	Measurement configuration	Separate feedthrough required	Maximum sample (diameter)	Maximum temperature
SH-1.00-G-EM	Grounded	No	Ø25 mm (1 in)	400 K
SH-1.00-I-EM	Isolated			
SH-1.00-C-EM ***	Coaxial	Yes*		
SH-1.00-T-EM ***	Triaxial	Yes**		

*Coaxial sample holders require one FT-BNC or FT-TRIAX feedthrough as listed below

**Triaxial sample holders require one FT-TRIAX feedthrough as listed below

***Cannot be used in combination with the 360° sample stage rotation option

Part number	Description
FT-BNC	Coaxial feedthrough and coaxial cable, installed and wired
FT-TRIAX	Triaxial feedthrough and coaxial cable, installed and wired

Site Requirements

Power — Standard single-phase (20 A maximum) power is required for instrumentation and optional pumps. The magnet power supply and optional recirculation chiller require 3-phase (21 A maximum) power.

Water — Electromagnet requires one supply and one return line for cooling with 7.6 L/min (2 gal/min) at a pressure drop of 30 psi. Magnet power supply requires 5.7 L/min (1.5 gal/min) at a pressure drop of 1.5 psi. Water temperature should be 15 °C to 25 °C.

Equipment Options

Part Number	Description
PS-360-EMPX	360° sample stage rotation—recommended when taking measurements using microwave probes NOTE: limits overall temperature range to 8 K to 400 K; ΔT between the sample and the sample stage temperature sensor is <±2 K over the full temperature range; consult Lake Shore for field upgrade
PS-FOA	Fiber optic probe arm modification. Transmit or receive light or IR/UV radiation. Fiber optic terminated with SMA connector or compression feedthrough NOTE: fiber optic and probe cannot be used simultaneously; consult Lake Shore for fiber optic selections
PS-Z16	16:1 zoom microscope upgrade; provides 4 μm resolution NOTE: ring light illumination not available for the PS-Z16 when used with the EMPX-HF and CPX-HF; consult Lake Shore for field upgrade

Equipment Options, continued

PS-LT	3.2 K base temperature assembly; 3.2 K to 400 K control range ; includes system modifications, stainless steel bellows and DS402 rotary pump NOTE: 50 Hz operation may increase base temperature; consult Lake Shore for field upgrade
PS-PLVI-25	Pump-line vibration isolator with NW 25 fittings and 1 m bellows; requires one bag of cement (not included) NOTE: for use with PS-LT or PS-HV-CPX
PS-V81DPC	Compact turbo pumping system; includes V-81 turbo pump with oil free dry scroll backing pump, high vacuum gauge, controller, and adaptors (specify 120 V/60 Hz or 220 V/50 Hz)
PS-PLVI-40	Pump-line vibration isolator with NW 40 fittings and 1 m bellows; requires one bag of cement (not included) NOTE: for use with PS-V81DPC
PS-LN2	50 L nitrogen Dewar with 12.7 mm (0.5 in) top withdrawal
PS-TLF-LNA	High flow capacity transfer line with shortened Dewar leg (500 mm (20 in) shorter than standard transfer line) for better fit with PS-LN2 NOTE: not compatible with FWPX
PS-DPC	Automatic Dewar pressure controller provides digital readout and pressure regulation over normal station operation NOTE: requires >68.9 kPa (10 psi) source of helium or nitrogen gas for use with either LHe or LN₂
PS-OAC	Oil-less compressor for PS-TMC (only available in 120 V)
PA-SEN	Additional probe arm sensor installed and wired to a 6-pin feedthrough (requires purchase of PS-PAB-10)
PS-PAB-10	Replacement probe arm and base (cable sold separately)
CS-5	75 to 250 μm pitch range calibration substrate for GSG probes—pad size: 50 μm ² ; calibration type: SOLT, LRL, LRM
CS-15	40 to 150 μm pitch range calibration substrate for GSG probes—pad size: 25 μm ² ; calibration type: SOLT, LRL, LRM
RC-EM7-208230-60-CE	Recirculating chiller; P-2, 208 to 230 V, 60 Hz, 15 A, 5000 W, 15.1 L/min (4 gal/min), 60 psi, TF-5000
RC-EM7-400-50-CE	Recirculating chiller; P-2, 380 to 400 V, 50 Hz, 3-phase, 20 A, 6425 W, 12.5 L/min (3.3 gal/min), 60 psi, TF-7500
RC-EM7-230-50-CE	Recirculating chiller; P-2, 200 V, 50 Hz, 15 A, 4400 W, 12.5 L/min (3.3 gal/min), 60 psi, TF-5000

Lake Shore Cryotronics is a leading supplier of cryogenic, superconducting magnet-based, electromagnet-based, high vacuum, and load-lock probe stations. We offer a full line of standard probe stations to meet your research requirements.

Our standard line of probe stations includes:

Model TTPX

- Up to six micro-manipulated probe stages
- Temperature range capabilities from 3.2 K to 675 K
- Up to 51 mm (2 in) diameter wafer capabilities
- Optical access through sample stage

Model CPX

- Up to six micro-manipulated probe stages
- Temperature range capabilities from 1.5 K to 675 K
- Up to 51 mm (2 in) diameter wafer capabilities
- ±5° sample stage rotation
- Load-lock and high vacuum options

Model FWPX

- Up to six micro-manipulated probe stages
- Temperature range capabilities from 3.5 K to 475 K
- ±5° sample stage rotation
- Up to 102 mm (4 in) diameter wafer capabilities

Model CPX-HF

- 1 T horizontal field split pair superconducting magnet
- Up to four micro-manipulated probe stages
- Temperature range capabilities from 2 K to 400 K with field on or off
- ±5° sample stage rotation
- Up to 25 mm (1 in) diameter wafer capabilities
- High vacuum option

Model CPX-VF

- 2.5 T vertical field solenoid superconducting magnet
- Up to six micro-manipulated probe stages
- Temperature range capabilities from 2 K to 400 K with field on or off
- ±5° sample stage rotation
- Up to 51 mm (2 in) diameter wafer capabilities
- High vacuum option

Model EMPX-HF

- 0.55 T horizontal (in-plane field) electromagnet
- Up to four micro-manipulated probe stages
- Temperature range capabilities from 3.2 K to 400 K
- Up to 25 mm (1 in) diameter wafer capabilities
- 360° sample stage rotation option

Model CRX-4K

- Low vibration, cryogen-free closed cycle refrigerator
- Up to six micro-manipulated probe stages
- Temperature range capabilities from 4.5 K to 475 K
- Up to 51 mm (2 in) diameter wafer capabilities

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